

D STATES PATENT AND TRADEMARK OFFICE

In re the Application of: Koji NOZAKI et al.

Group Art Unit: 1752

Application Number: 10/623,679

Examiner: Amanda C. Walke

Filed: July 22, 2003

Confirmation Number: 5083

For:

RESIST PATTERN THICKENING MATERIAL, RESIST PATTERN

AND PROCESS FOR FORMING THE SAME, AND SEMICONDUCTOR DEVICE AND PROCESS FOR

MANUFACTURING THE SAME

Attorney Docket Number:

030891

Customer Number:

38834

## PETITION FOR EXTENSION OF TIME

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450 July 6, 2007

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated February 8, 2007 for two months from May 8, 2007 to July 8, 2007.

Attached please find a check in the amount of \$630.00 to cover the cost of the extension (\$450.00) and the Information Disclosure Statement (\$180.00). If any additional fees are due in connection with this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP

Shuji Aoshizaki

07/09/2007 AWDNDAF1 00000069 10623679

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Limited Recognition

450.00 OP

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Enclosure:

Check of \$630.00